

**AMENDMENTS TO THE CLAIMS**

**This listing of claims will replace all prior versions and listings of claims in the application:**

**LISTING OF CLAIMS:**

1. (currently amended): A magneto-resistance device comprising:  
  
an anti-ferromagnetic layer;  
  
a pinned ferromagnetic layer having a fixed spontaneous magnetization and coupled with said anti-ferromagnetic layer ~~such that a direction of spontaneous magnetization of said pinned ferromagnetic layer is fixed~~;  
  
a non-magnetic tunnel insulating layer coupled with said pinned ferromagnetic layer; and  
  
a free ferromagnetic layer coupled with said tunnel insulating layer and having a reversible free spontaneous magnetization,  
  
wherein said pinned ferromagnetic layer comprises a first composite magnetic layer configured to prevent at least one of elements of said anti-ferromagnetic layer from diffusing into said tunnel insulating layer.
2. (Original) The magneto-resistance device according to claim 1, wherein said anti-ferromagnetic layer contains Mn, and  
  
said first composite magnetic layer prevents said Mn from diffusing into said tunnel insulating film.
3. (currently amended): The magneto-resistance device according to claim 1 [or 2], wherein said first composite magnetic layer comprises:

ferromagnetic material that has been not oxidized; and  
oxide of a material which is easy to combine with oxygen compared with said  
ferromagnetic material.

4. (Original) The magneto-resistance device according to claim 3, wherein said  
ferromagnetic material contains Co in as a main component.

5. (currently amended): The magneto-resistance device according to claim 1 ~~any of  
claims 1 to 4~~, wherein said first composite magnetic layer is formed from a region of an  
amorphous phase as a whole or from a region of said amorphous phase and a region of a  
crystalline phase.

6. (Original) The magneto-resistance device according to claim 5, wherein said  
crystalline phase region contains a plurality of crystal regions, and

said plurality of crystal regions pass through said first composite magnetic layer into a  
direction of a thickness of said first composite magnetic layer.

7. (currently amended): The magneto-resistance device according to claim 5 [or 6],  
wherein a composition of said amorphous phase in said first composite magnetic layer is  $D_ZM_1$   
 $_Z O_X$  ( $0.6 \leq Z \leq 0.9$ , and  $X > 0$ ),

said D is at least one selected from the group consisting of Co, Fe and Ni, and

said M is at least one selected from the group consisting of Ta, Zr, Hf, Nb, and Ce.

8. (currently amended): The magneto-resistance device according to claim 1 ~~any of  
claims 1 to 4~~, wherein said first composite magnetic layer contains a plurality of crystal grains  
comprising [said] ferromagnetic material,

PRELIMINARY AMENDMENT  
National Stage Entry of PCTJP03\16067

said plurality of crystal grains are separated from each other by [said] oxide, and  
a part of said plurality of crystal grains contacts an adjacent one of said plurality of  
crystal grains.

9. (Original) The magneto-resistance device according to claim 8, wherein said oxide  
comprises oxide of at least an element selected from the group consisting of Al, Si, Mg and Ti.

10. (currently amended): The magneto-resistance device according to claim 1 ~~any of  
claims 1 to 4~~, wherein said first composite magnetic layer contains a plurality of crystal grains  
comprising [said] ferromagnetic material, and

said plurality of crystal grains are separated from each other by [said] oxide and pass  
through said first composite magnetic layer into a direction of a thickness of said first composite  
magnetic layer.

11. (Original) The magneto-resistance device according to claim 10, wherein a part of  
said plurality of crystal grains contacts an adjacent one of said plurality of crystal grains.

12. (currently amended): The magneto-resistance device according to claim 10 [or 11],  
wherein said oxide comprises oxide of at least an element selected from the group consisting of  
Al, Si, Mg, Ti, Ta, Hf, Zr, Nb and Ce.

13. (currently amended): The magneto-resistance device according to claim 8 ~~any of  
claims 8 to 12~~, wherein a thickness of said oxide is thinner than a grain diameter of each of said  
plurality of crystal grains.

14. (Original) The magneto-resistance device according to claim 13, wherein the  
thickness of said oxide is equal to or less than 2 nm.

PRELIMINARY AMENDMENT  
National Stage Entry of PCT/JP03/16067

15. (Original) The magneto-resistance device according to claim 14, wherein an average grain diameter of said plurality of crystal grains is equal to or less than 10 nm.

16. (currently amended): The magneto-resistance device according to claim 8 ~~any of claims 8 to 15~~, wherein ferromagnetic coupling is kept between said plurality of crystal grains.

17. (currently amended): The magneto-resistance device according to claim 1 ~~any of claims 1 to 16~~, wherein said pinned ferromagnetic layer further comprises a first metal ferromagnetic layer and a second metal ferromagnetic layer, and

said first composite magnetic layer is interposed between said first metal ferromagnetic layer and said second metal ferromagnetic layer.

18. (currently amended): The magneto-resistance device according to claim 1 ~~any of claims 1 to 17~~, wherein a resistivity of said first composite magnetic layer is in a range of 10  $\mu\Omega\text{cm}$  to 3000  $\mu\Omega\text{cm}$ .

19. (currently amended): The magneto-resistance device according to claim 1 ~~any of claims 1 to 18~~, wherein said free ferromagnetic layer comprises:

a second composite magnetic layer configured to prevent at least one elements of said free ferromagnetic layer from diffusing into said tunnel insulating layer.

20. (Original) The magneto-resistance device according to claim 19, wherein said free ferromagnetic layer contains Ni, and

said second composite magnetic layer prevents said Ni from diffusing into said tunnel insulating film.

PRELIMINARY AMENDMENT  
National Stage Entry of PCTJP03\16067

21. (currently amended): The magneto-resistance device according to claim 20, wherein said free ferromagnetic layer comprises:

a metal ferromagnetic layer, ~~one of whose boundaries is connected to~~ provided between said tunnel insulating layer and ~~the other of whose boundaries is connected to~~ said second composite magnetic layer; and

a soft magnetic layer containing said Ni and connected to ~~a boundary of~~ said second composite magnetic layer ~~which is on~~ an opposite side to said metal ferromagnetic layer.

22. (currently amended): The magneto-resistance device according to claim 1 [or 2], wherein said pinned ferromagnetic layer comprises:

a non-magnetic layer; and

two ferromagnetic layers anti-ferromagnetically coupled to each other through said non-magnetic layer.

23. (currently amended): The magneto-resistance device according to claim 19 [or 20], wherein said free ferromagnetic layer comprises:

a non-magnetic layer; and

two ferromagnetic layers anti-ferromagnetically coupled through said non-magnetic layer.

24. (currently amended): A magnetic memory comprising[:]

[said] a magneto-resistance device according to any of claims 1 to 23 which comprises:  
an anti-ferromagnetic layer;

PRELIMINARY AMENDMENT  
National Stage Entry of PCTJP03\16067

a pinned ferromagnetic layer having a fixed spontaneous magnetization and coupled with said anti-ferromagnetic layer;

a non-magnetic tunnel insulating layer coupled with said pinned ferromagnetic layer; and  
a free ferromagnetic layer coupled with said tunnel insulating layer and having a reversible free spontaneous magnetization,

wherein said pinned ferromagnetic layer comprises a first composite magnetic layer configured to prevent at least one of elements of said anti-ferromagnetic layer from diffusing into said tunnel insulating layer.

25. (Cancelled)

26. (Cancelled)

27. (Cancelled)

28. (new): The magnetic memory according to claim 24, wherein said free ferromagnetic layer comprises:

a second composite magnetic layer configured to prevent at least one elements of said free ferromagnetic layer from diffusing into said tunnel insulating layer.

29. (new): A magneto-resistance device comprising:

an anti-ferromagnetic layer;

a pinned ferromagnetic layer having a fixed spontaneous magnetization and coupled with said anti-ferromagnetic layer;

an intermediate layer coupled with said pinned ferromagnetic layer; and

PRELIMINARY AMENDMENT  
National Stage Entry of PCTJP03\16067

a free ferromagnetic layer coupled with said intermediate layer and having a reversible free spontaneous magnetization,

wherein at least one of said pinned ferromagnetic layer and said free ferromagnetic layer comprises a first composite magnetic layer configured to prevent at least one of elements of a corresponding one of said anti-ferromagnetic layer and said free ferromagnetic layer from diffusing into said intermediate layer.